

RESPONSE UNDER 37 CFR 1.116 **EXPEDITED PROCEDURE EXAMINING GROUP 2814**

PATENT APPLICATION Do. No. 4591-170 Client No. IE10189-US

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of: Jong-Ho LEE and Nae-In LEE

Serial No.

09/776,059

Examiner:

Wille, Douglas A

Confirmation No.

9369

Filed:

February 2, 2001

Group Art Unit: 2814

For:

DIELECTRIC LAYER FOR SEMICONDUCTOR DEVICE AND

METHOD OF MANUFACTURING THE SAME

Mail Stop AF Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

AMENDMENT AFTER FINAL REJECTION UNDER 37 CFR 1.116

Responsive to the Final Office Action, Paper No. 0604, dated June 8, 2004, please amend the application as follows.

Amendments to the Claims are reflected in the listing of claims which begins on page 2 of this paper.

Remarks/Arguments begin on page 10 of this paper.

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